



# High precision automated tab assembly

Hansruedi Moser & Guido Bonati für den CSEM Workshop am 24.02.2022

## INTRO

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### FIGURES

- Established in 1957
- Located in St. Gallen, Switzerland
- Subsidiaries in Germany, USA and China
- Annual Turnover >65 Million USD
- Privately owned

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### BUSINESS FIELDS

- LIFE SCIENCE  
Cytometry, Endoscopy, Intra Oral
- ADVANCED MANUFACTURING  
Fiber Laser Pumping, Direct Diodelasers  
Semicon Vision Systems
- DEFENCE  
Optoelectronical Components and Systems

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### PRODUCT/TECHNOLOGY RANGE

- Optical and Mechanical Engineering Services
  - Flats and Classic lenses, PML Asheres Production
  - Optical Coatings
  - EO Assemblies, High precision micro assembly
  - SM Laser Systems 400...1600nm, <100mW
- 

your needs

## PRODUCT

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### FAC MARKETS

- Used to collimate semiconductor lasers
- Huge demand generated due to the success of fiberlasers (IPG, China)
- Niche Markets for special assemblies  
<1.000.000 p.a.

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### WHY SPECIALS

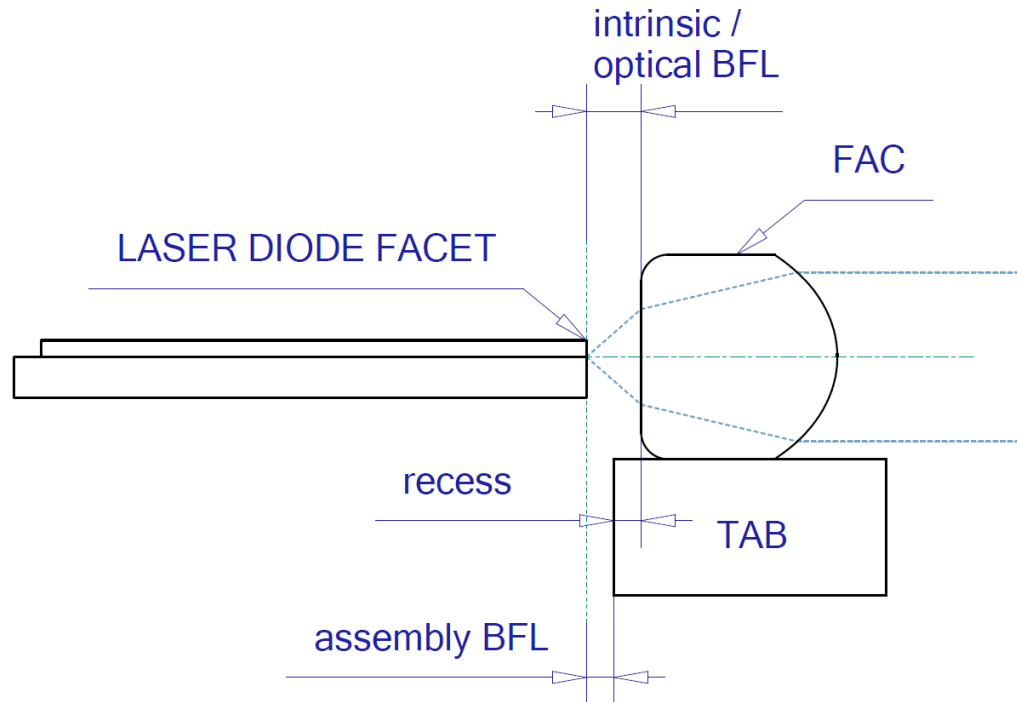
- In special arrangements, people like to mount underneath the lens or above, dependin on their geometry
- High precision arrangements need an highly accurate thickness of the glue film
- Customers pay for this assemblies as it saves them even higher costs in their process

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### ALTERNATIVES

- Manuel mounting in china by using fixtures  
possible individual quality check as costs as well  
precision is historically worse
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## FAC on bottom tab assembly



- Intrinsic / optical back focal length (BFL) determining the distance to the laser diode facet
- «assembly BFL» (bonding gap) = BFL – recess
- Goal: assembly of FAC on tab with low variance for bonding gap, therefore with low tolerance in the «assembly BFL»
- Tolerance +/- 5 micron



# FISBA

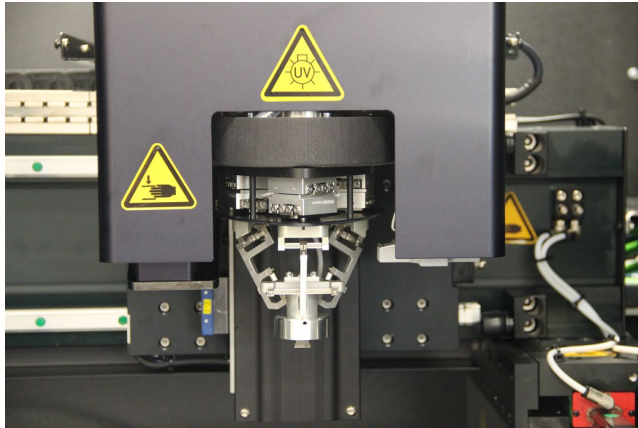
## Automation Platform



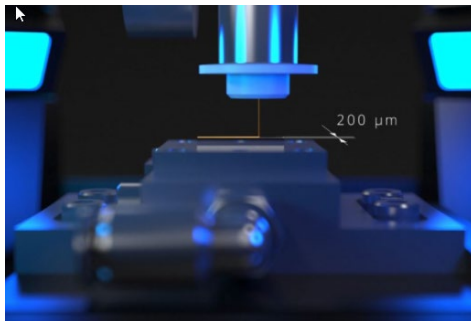
- 6-axis Micromanipulator plus gantry
- Glue Dispenser
- Machine Vision for passive alignment
- Beam Diagnostic System with Laser Diode bar (IR) for active alignment
- Tray access via gantry
- 24h Autonomous Operation, <1‰ Failure Rate

# FISBA

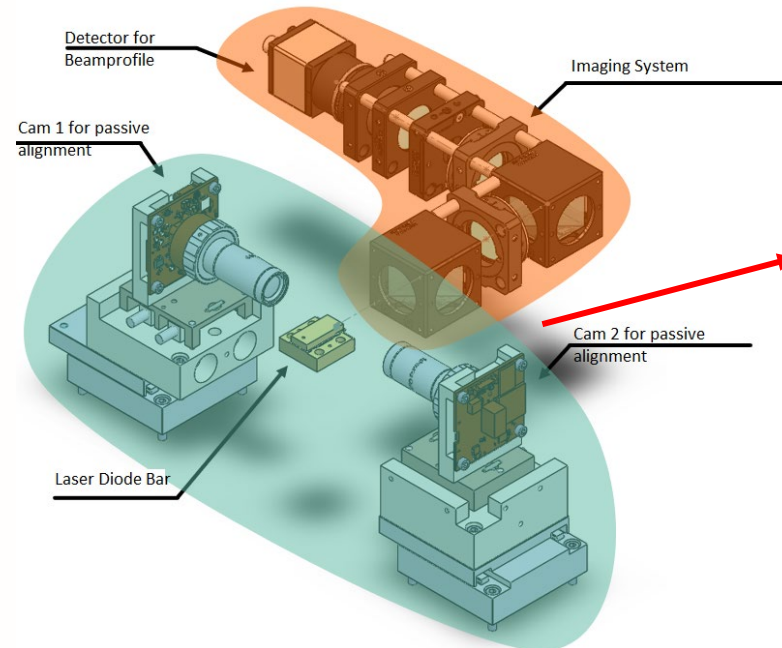
## Modules



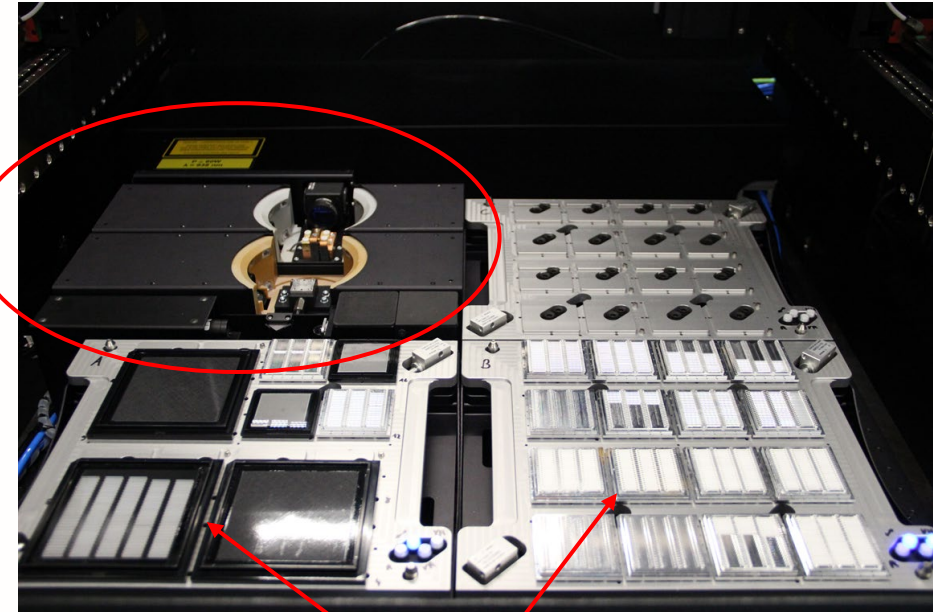
6-axis Micromanipulator



Jet-dispenser

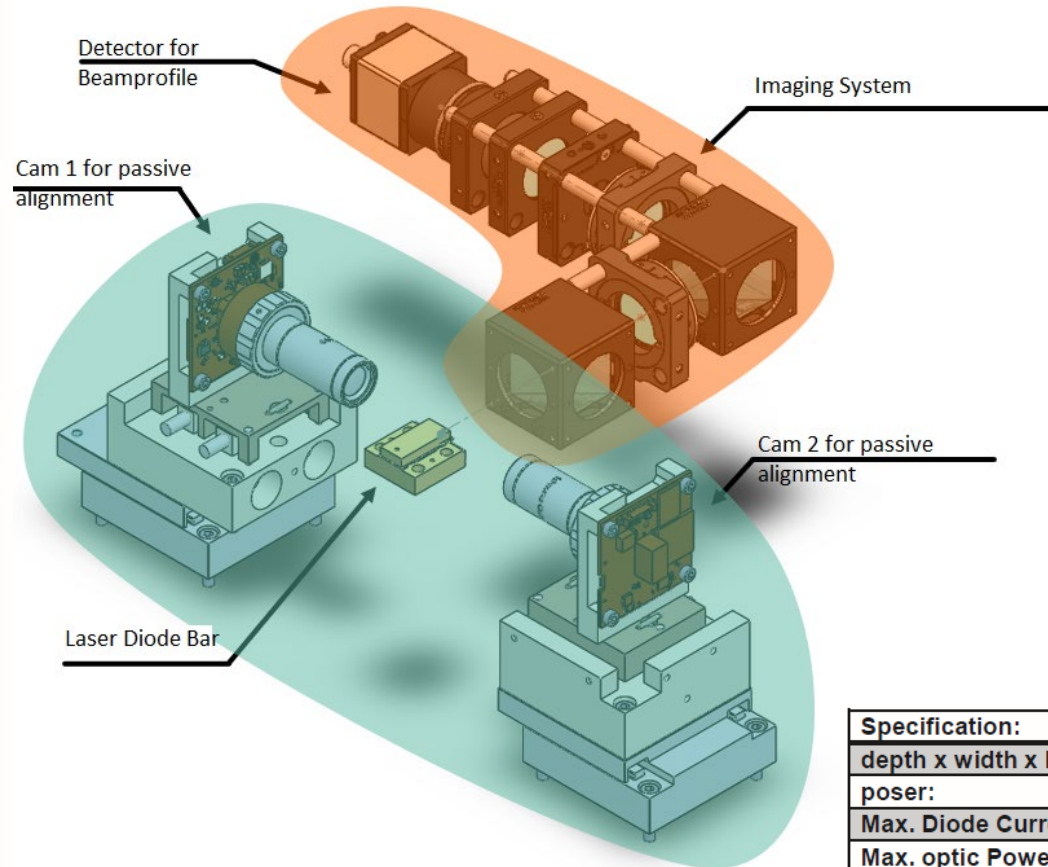


Passive and active measuring system



Variable Trays

## Beam diagnostic measurement system

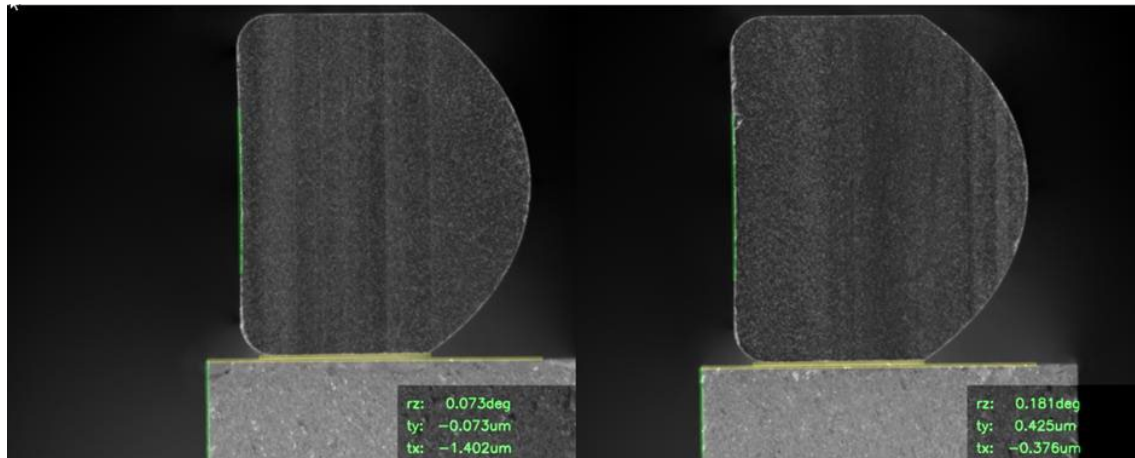


- Two independent measurement system for BFL and Laser beam parameters such as smile and residual divergence
- Passive CMOS imaging with resolution of 1.3 micron / pixel
- Active Laserbeam profiling with resolution of 0.032 micron / pixel (@ EFL of FAC at 600 micron)
- Allowing automated routine-based full positioning measurement and bonding cycle

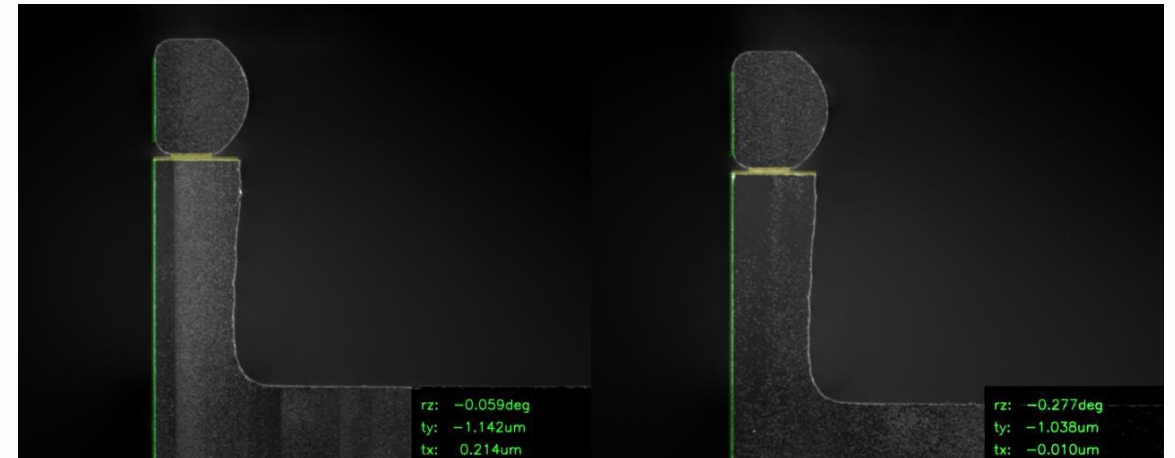
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|--|--|
| <b>Specification:</b>                                      |  |
| <b>depth x width x height (incl. SVM)</b>                  | 250 x 350 x 127 mm   |
| <b>poser:</b>  | 5V DC  |
| <b>Max. Diode Current:</b>                                 | 50A  |
| <b>Max. optic Power Ausgangsleistung:</b>                  | dependent on diode laser used  |
| <b>Measurement resolution passive image:</b>               | 1,325 $\mu\text{m}/\text{px}$  |
| <b>Measurement resolution active position (Fast-Axis):</b> | dependent on EFL (f) [mm] of FAC-Lens under test:<br>$A = 5,3 * 10^{-5} * f_{FAC}$ for a FAC-Lens with f=0,6mm this results in a resolution of 0,032 [ $\mu\text{m}/\text{px}$ ] |



## Assembly examples



FAC 600 on bottom tab (EFL = 600 micron)

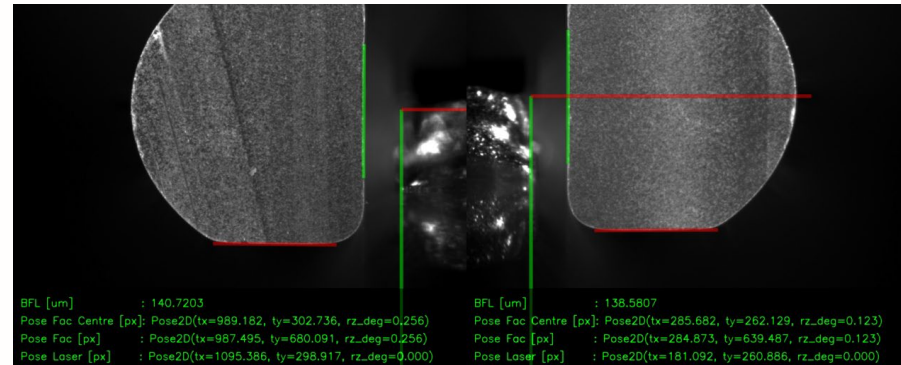
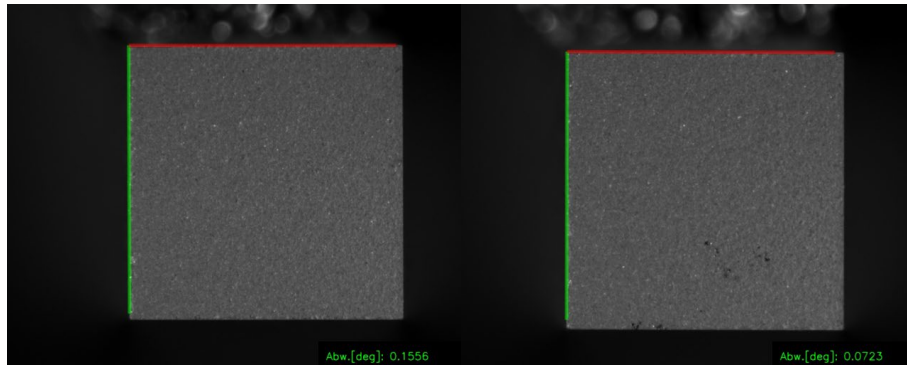


FAC 200 on bottom tab (EFL = 200 micron)



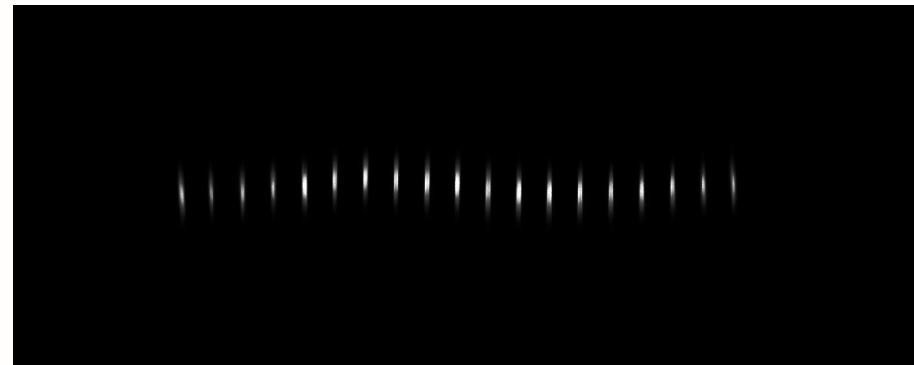
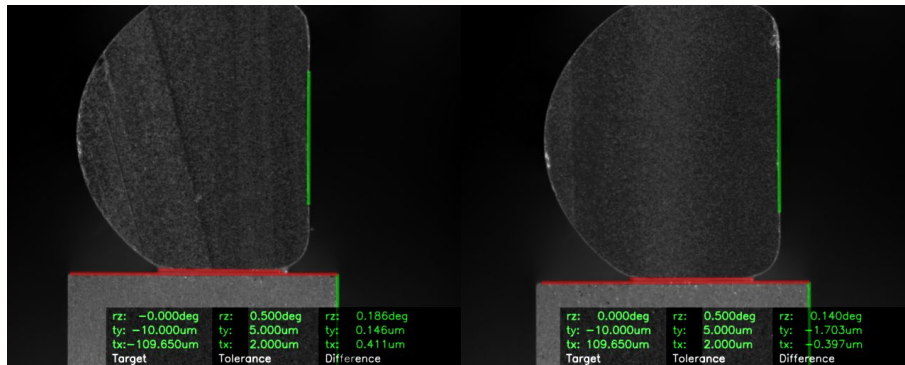


## Assembly steps (FAC 600 on bottom tab)



Passive measurement of bottom tab

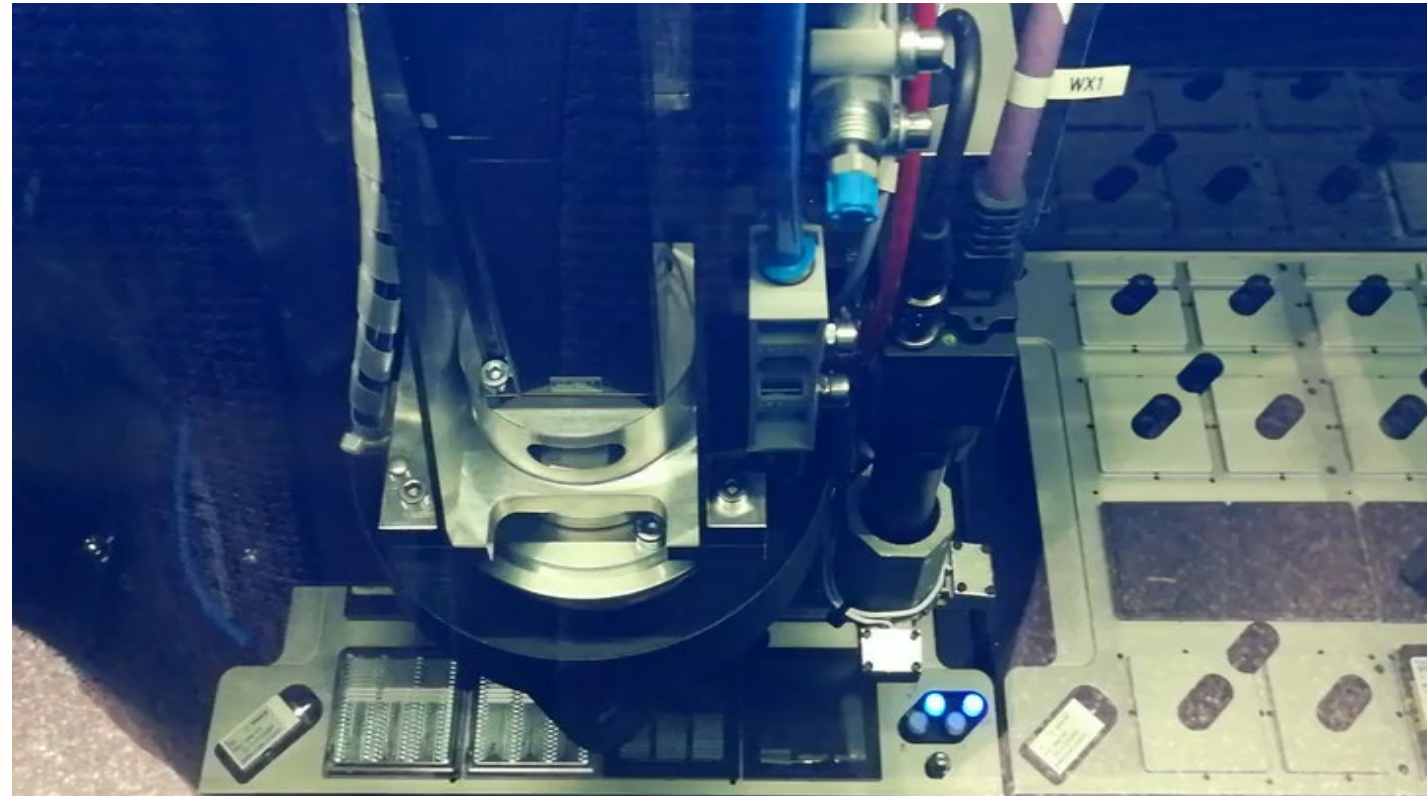
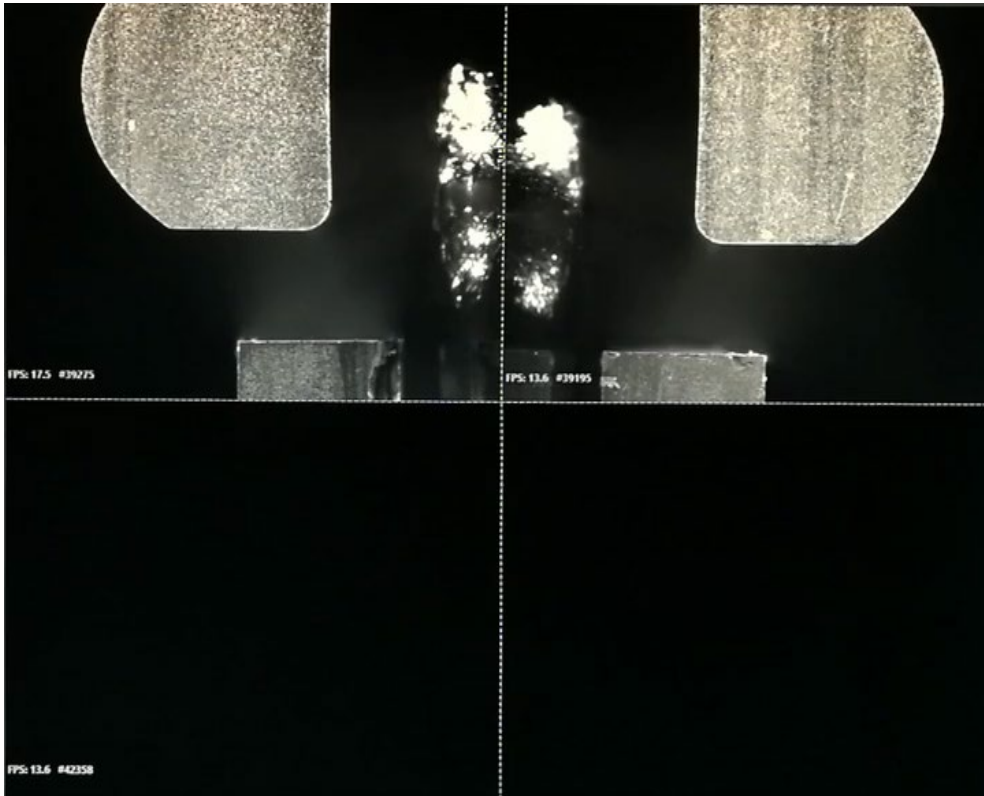
Aktive measurement of BFL FAC



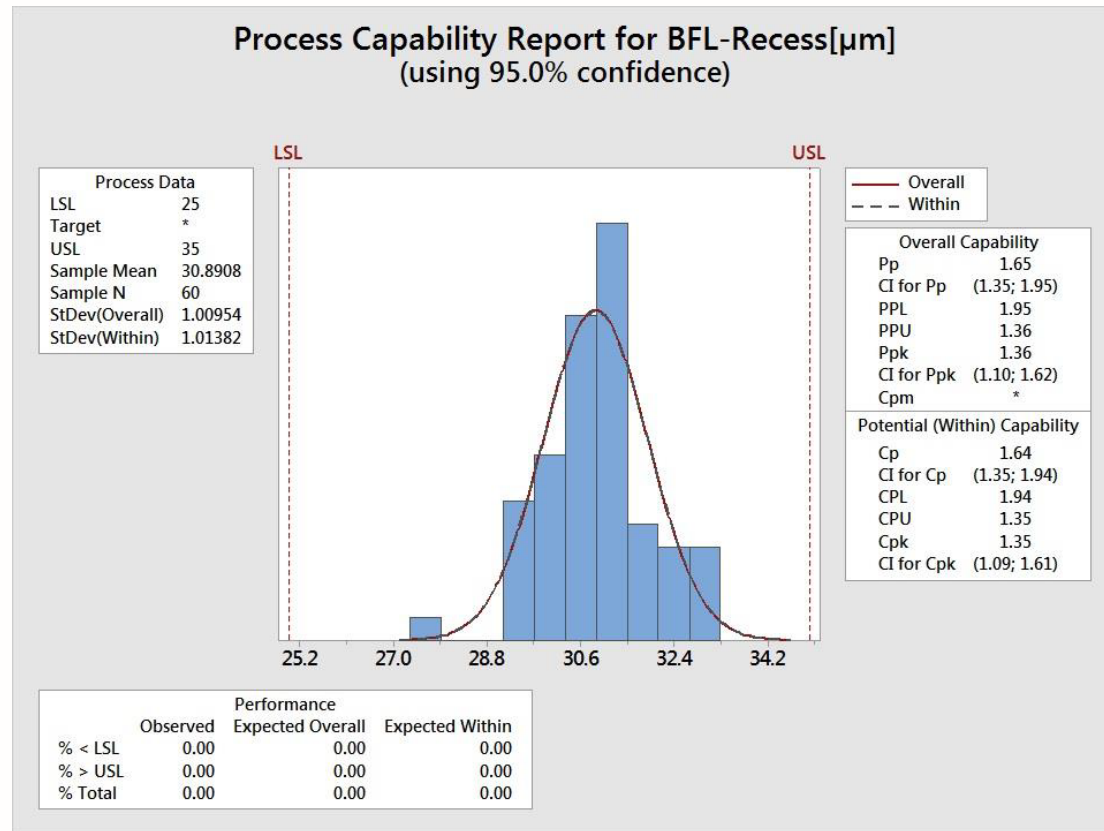
Passive measurement and bonding with recess = BFL FAC – fix «assembly BFL» (30 micron)

# FISBA

## Videos / Closeup der Kameras (links)



## Process Capability for assembly BFL



- A lot of 60 pieces FAC's with EFL of 600 micron was subject to a process capability test for the «assembly BFL» measurement
- A standard deviation for the «assembly BFL» of +/- 1.0 micron is achieved
- The process capability of Ppk of 1.36 is indicative for a stable process

FAC 600 on bottom tab with «assembly BFL» = 30 micron

